

CORRIGENDUM

No. IIT Mandi/Admin/PUR-155/2014-15/7732-33

Date: 26.02.2015

To

1. Institute Website IIT Mandi
2. Central Public Procurement Portal.

Sub: -Corrigendum to NIT No.IITMandi/Admin/PUR-155/2014-15/7543-44 dated 13.02.2015 regarding supply & installation of Atomic Layer Deposition.

The following changes are made to the specification of the **Atomic Layer Deposition**.

Sr. No.	Specification mentioned in Tender document	Should be read as
1.	Sr. No. 1 Deposition temperature range: “25°C or room temperature whichever the higher to 350°C or more”	“25°C or room temperature whichever the higher to 300°C or more”
2.	Sr. No.2 Deposition uniformity: : “Deposition uniformity of ±1% on 200 mm substrate”	“Deposition uniformity of ±1% on 100 mm substrate”.
3.	Sr. No.3 Reaction chamber : “Dome Lid, Heater Jacket, around 65 mm head clearance preferred”	Dome Lid, around 65 mm head clearance preferred”
4.	Sr. No.6 Total Precursor lines : “Six precursor lines with few organometallic precursors with individual heating, plus N2 Carrier Gas, plus existing option for 0.01 Torr vapor pressure precursors”	Four or more precursor lines with few organometallic precursors with individual heating, plus N2 Carrier Gas, plus existing option for 0.01 Torr vapor pressure precursors”.

Those who have already sent their bids as per earlier technical specification can send their revised bids in the light of the correct technical specification as mentioned above. However, they need not submit bid fee & EMD again.

All other terms and conditions will remain the same.

Sd/-
Assistant Registrar
(Stores & Purchase)